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Contents

v *Authors*
vii *Conference Committee*

SESSION 1 OPTOMECHANICAL DESIGN AND OPTIMIZATION

- 11100 02 **Optomechanical design considerations for a vacuum window for optical and infrared interferometry [11100-1]**
- 11100 03 **Development of a mirror mount suitable for laboratory and OEM applications [11100-2]**
- 11100 04 **Design and test of a compound curved beam flexure with off-axis actuation for precision optical alignment [11100-3]**
- 11100 05 **Optomechanical design of a portable metrology system for measurement of precision rotary stage errors [11100-4]**
- 11100 06 **The optomechanical design for the Off-plane Grating Rocket Experiment (OGRE) [11100-5]**
- 11100 07 **Structural optimization of system WFE [11100-6]**
- 11100 08 **Global optimization using LLIMAS for the design of vibration isolation systems of high-uncertainty payloads [11100-8]**
- 11100 09 **Mirror topology optimization [11100-25]**

SESSION 2 OPTOMECHANICAL ANALYSIS

- 11100 0A **Obtaining finite element thermal loads from fluence maps and voxels [11100-9]**
- 11100 0B **Finite element modeling of a laminar flexure bending mechanism for elliptically bent hard x-ray mirror [11100-10]**

SESSION 3 OPTOMECHANICAL SYSTEMS, MECHANISMS, AND DEVICES

- 11100 0E **System engineering of complex optical systems: requirements and verification documents [11100-13]**
- 11100 0G **Anomalous behavior of Transiting Exoplanet Survey Satellite (TESS) optical assembly: root cause investigation reveals crystallization of RTV 566 at low temperatures [11100-15]**

- 11100 OH **High loading precision rotation stage design for synchrotron radiation mirror stitching measurement** [11100-16]
- 11100 OI **Using a digital still camera for shearography: preliminary experiments and observations** [11100-18]

POSTER SESSION

- 11100 OJ **Design and development of large SiC mirror for spaceborne application** [11100-19]
- 11100 OL **Conceptual and test phase of optical design of seeker in missile application** [11100-21]
- 11100 OM **Effect of beam steering method on optical system** [11100-22]
- 11100 ON **Design of dual mode seeker for millimeter wave and four-quadrant detectors in missile application** [11100-23]
- 11100 OO **Stabilization effects on seeker performance in missile application** [11100-24]

Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Abedin, Kazi Monowar, 0I
Ahmad, Anees, 0E
Al Jabri, Awatif Rashid, 0I
Al Shidhani, Saleh Said, 0I
Allgood, Kim D., 06
Anton, Jayson W. J., 0B
Assoufid, Lahsen, 0B
Biskach, Michael P., 06
Bisson, Gary, 07, 0A
Chan, Kai-Wing, 06
Chen, Bo-Yi, 0H
Clark, James H., III., 02
Cox, Brian C., 04
De Andrade, Vincent, 05
DeWitt, Frank A., 03
Donovan, Benjamin D., 06
Doyle, Keith B., 0G
Fung, Hok-Sum, 0H
Genberg, Victor L., 07, 0A
Harder, Ross, 0B
Hlinka, Michal, 06
Holland, Andrew D., 06
Holland, Karen, 06
Hsu, Ming-Ying, 0H
Huang, Yu-Shan, 0H
Kearney, John D., 06
Kearney, Steven P., 05, 0B
Lee, Chien-yu, 0H
Lee, Yun Woo, 0J
Lewis, Matthew R., 06
Lin, Shang-Wei, 0H
Maser, Jörg, 05
Mashrafi, Sheikh T., 0B
Mazzarella, James R., 06
McEntaffer, Randall L., 06
Michels, Gregory J., 07, 0A
Moon, Il Kweon, 0J
Mooney, Tim M., 0B
Mower, Todd M., 0G
Murray, Neil J., 06
Mutters, David K., 09
Numata, Ai, 06
O'Meara, Bridget C., 06
Penado, F. Ernesto, 02
Qian, Jun, 0B
Rahman, S.M. Mujibur, 0I
Rey, J., 08
Riveros, Raul E., 06
Saha, Timo T., 06
Sakarya, Doğan Uğur, 0L, 0M, 0N, 0O
Sari, Hüseyin, 0L, 0M, 0N, 0O
Schultz, Ted B., 06
Shi, Bing, 0B
Shi, Xianbo, 0B
Shu, Deming, 05, 0B
Solly, Peter, 06
Soman, Matthew R., 06
Stoekel, G., 08
Tutt, James H., 06
Wang, Duan-Jen, 0H
Wellman, John A., 0G
Yang, Ho-Soon, 0J
Yin, Gung-Chian, 0H
Zhang, William W., 06

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